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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE  
(207.005-US)

Application of: **Partridge et al.**

) Group Art Unit: **1762**

Serial No: **10/713,172**

) Examiner:

Filed: **November 14, 2003**

)

Title: **Crack and Residue Free Conformal Deposited  
Silicon Oxide with Predictable and Uniform  
Etching Characteristics**

)

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage in an envelope addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on May 12, 2004

Date

Michiko Siter  
(person signing this certificate)

Michiko Siter  
Signature

**FIRST INFORMATION DISCLOSURE STATEMENT**

Dear Sir:

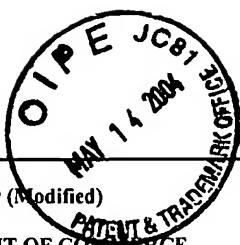
Submitted herewith is one (1) sheet of a modified Form PTO-1449. A copy of each document cited on the attached Form PTO-1449 is also submitted.

It is respectfully requested that the Examiner make his/her consideration of these documents formally of record with the initial Office Action.

Respectfully submitted,

Neil A. Steinberg  
Reg. No. 34,735  
650-968-8079

Date: May 12, 2004



Sheet 1 of 1

 <b>PTO-1449 (Modified)</b> <b>U.S. DEPARTMENT OF COMMERCE</b> <b>PATENT AND TRADEMARK OFFICE</b>	<b>ATTY. DOCKET NO.</b> <b>207.005-US</b>	<b>SERIAL NUMBER</b> <b>10/713,172</b>
	<b>APPLICANT(S)</b> <b>Partridge et al.</b>	
<b>INFORMATION DISCLOSURE STATEMENT</b> <b>BY APPLICANT</b>	<b>FILING DATE</b> <b>November 14, 2003</b>	<b>GROUP ART UNIT</b> <b>1762</b>

## **U.S. PATENT DOCUMENTS**

## **FOREIGN PATENT DOCUMENTS**

EXAMINER INITIALS	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION YES/NO

**OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)**

**CHANGES & COMMENTS (including Reviewer, Time, Date, Document Number, etc.)**

<b>EXAMINER</b>	<b>DATE CONSIDERED</b>
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**EXAMINER:** Initial citation if reference was considered. Draw line through citation if not in conformance to MPEP 609 and not considered. Include copy of this form with next communication to applicant.